

Attorney Docket: 081468-0306369

Client Reference: P-1790.000-US



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of:
JOOST JEROEN OTTENS, ET AL.

Confirmation Number: 4455

Application No.: 10/743,272

Group Art Unit: 1756

Filed: December 23, 2003

Examiner: Christopher G. Young

Title: OPTIMIZED CORRECTION OF WAFER THERMAL DEFORMATIONS IN A
LITHOGRAPHIC PROCESS

AMENDMENT UNDER 37 C.F.R. §1.111

Mail Stop Non-Fee Amendments

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated December 20, 2006, the date for responding
being March 20, 2007, please amend the above-identified application as follows:

03/21/2007 HVUONG1 00000051 033975 10743272

01 FC:1201 1400.00 DA